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Millimeter-Scale Hexagonal Boron Nitride Single Crystals for Nanosheet Generation

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ABSTRACT

Development of next generation two-dimensional (2D) transistors or photo-electronic devices is closely linked to advances in 2D materials. Due to its outstanding properties (insulating, stable,

inert, transparent, isostructural to graphene...), hexagonal boron nitride (hBN) crystal and in particular its exfoliated nanosheets form, is a choice material to fabricate sensors or plasmonic and photonic devices. However, a wide development of these heterostructures still suffers from a lack of large samples and in ample supply. In this context, we propose the fabrication of large exceptional quality hBN single crystals of more than few millimeters lateral size by using polymer route combined with a sintering process. The structural quality and compositional purity are retained after exfoliation and dry transfer of these free standing Boron Nitride NanoSheets (BNNSs) onto Si substrates. This developed method can be achieved under short and soft conditions and leads to BNNSs with lateral sizes of several hundreds of microns. This work paves the way for a wide use of BNNS for 2D material applications.

INTRODUCTION

Produced as nanomaterial, hBN, as an excellent dielectric material, can be suitable for many applications that require BNNSs ranging from one to hundreds of layers. Its atomically flat surface, with no dangling bonds nor charge traps on the surface¹ make it very interesting as a substrate^{2–4} or encapsulating layer^{5,6} for two-dimensional materials, intercalant in Van der Waals heterostructures,⁷ gate dielectric,^{8,9} counter electrode in dye-sensitized solar cells,¹⁰ and many others.¹ hBN also possesses excellent photoelectric properties such as distinct violet or ultraviolet (UV) luminescence emissions, making it all the more attractive for optoelectronic devices, such as deep ultraviolet light emitting devices,^{11,12} UV photoconductive detectors¹³ and single photon emitters.¹⁴ In this rich applicative context, BNNSs are highly desirable as a building blocks (substrate, intercalant or encapsulating layer) for 2D heterostructures, and 2D-

hBN has become among the most sought inorganic 2D material.¹⁵ However, it is obvious that generating efficient 2D electronic devices requires from the beginning high quality hBN substrate displaying crystalline and chemical purity as well as wafer scale size. Up to now, two main strategies to produce BNNSs have been proposed, involving either "bottom-up" or "topdown" approaches.¹⁶ Bottom-up routes mainly include Chemical Vapor Deposition (CVD)¹⁷⁻¹⁹ and derivatives (LPCVD,²⁰ MOCVD,^{21,22}). Ion Beam Sputtering Deposition (IBSD)²³ and Molecular Beam Epitaxy (MBE)²⁴. While these bottom-up approaches have the potential for large surface areas, the synthesis of a single-crystal hBN film still remains elusive and let alone high quality transfer at the wafer-scale.²⁵ Furthermore, they may be affected by the morphology of the substrate and the reactants purity.²⁶⁻²⁸ Top-down methods rely on mechanical^{16,29,30} or chemical³¹ exfoliation from bulk hBN crystals that can be either commercial ones or lab-scale samples. A first commercial source³² is obtained from an oxygen-containing boron compound reacting with a nitrogen-containing source. These materials exhibit quite small crystalline domains (from sub-micron up to 10 µm) which are not so convenient for exfoliation. Besides, HQ Graphene,³³ a commercial supplier, claims the production of high quality crystals with a size reaching 1 mm, but there is no real information about the chemical process used to synthesize this material and the exfoliated sheets demonstrate a loss of their lateral size.^{33,34} Beyond commercial ones, samples supplied by NIMS lab are used by most of the research groups over the world.^{35–37} Since they can offer exceptional quality samples with large lateral size which can be almost retained after exfoliation, the fabrication technique is based on severe conditions of pressure and temperature that could limit upscaling or industrial processes.³⁵ Still starting from a molten solvent system, Edgar's group is now coming close to achieving the similar quality samples by a simpler and cheaper process.^{38,39} However, they currently have ten times more

crystal defects, or imperfections, in their structure³⁵ and it can be mentioned that the process is a bit long (more than 80 hours).³⁸ In our group, we have recently developed a new hBN synthesis approach by combining a polymer route with a sintering process to achieve polycrystalline samples made of more than 200 μ m² single crystals.^{40,41} This process deals with softer conditions of pressure and temperature and shorter time but gives samples that do not reach yet the required quality for 2D devices. In this paper, we will show that, by improving our process in term of sintering conditions and chemistry of the system, we are now able to deliver transparent exceptionally high structural quality boron nitride single crystals of more than 1 mm in lateral size.

RESULTS AND DISCUSSION

Material synthesis.

Polymer Derived Ceramics pathway is known for many years to produce hexagonal boron nitride from borazine precursor. However, this chemical process requires quite high temperatures (more than 1800°C) to get perfectly crystallized hBN.⁴² In this context, addition of a crystallization promoter (like Li₃N) is now commonly used to enhance cristallinity at lower temperatures.^{19,43} In order to go further in the crystallization rate, our group has previously demonstrated the possibility to use an additivated preceramic polymer in a SPS system.^{40,41} Here, we show how, by tuning the sintering process and the additive content, we can get millimeter-scale hBN single crystal that can be used to generate BNNSs. Figure 1 illustrates the whole process. Freshly distillated borazine is first polycondensed into a less volatile and thus more processable liquid polyborazilene (PBN). A mixture of PBN and 35 wt.% Li₃N is then preceramized at 650°C under N₂ for 1h to form the preceramic powder which is placed into a BN crucible itself introduced into a pressure-controlled furnace. Based on preliminary results, optimal sintering conditions have been determined to be a temperature of 1800°C, a pressure of 180MPa and a dwelling time of 8h.



Figure 1. Scheme illustrating the hBN synthesis starting from borazine.

As-obtained bulk material. Naked eyes and optical microscopy observations of the as-sintered sample (Figure 2a and 2b) reveal that it is composed of faceted millimeter-sized regions, which is similar with the domain size of ~1 mm obtain by Edgar's group³⁸ and a bit lower than the few millimeters obtain by NIMS group.³⁶ The X-Ray Diffraction (XRD) pattern (Figure 2c) shows only well-separated, thin single peaks that all can be assigned to the crystallographic planes of hBN crystal, as described in the standard JCPDS database (00-034-0421). This demonstrates the perfect structural ordering of the hBN sample, as confirmed by Raman spectrometry. The Raman spectra were recorded in two frequency shift ranges and exhibit two single peaks (Figure 2d and 2e). The low frequency peak at 52.6 cm⁻¹ (FWHM of about 1.2 cm⁻¹) corresponds to interlayer

vibrations, referred to as the interlayer shear mode.^{44,45} The second peak, measured at 1366.0 cm⁻¹, exactly matches the value expected for the in-plane shear mode E_{2g} symmetry of hBN.^{29,44 46,47} This high frequency peak has a FWHM of about 7.6 cm⁻¹, which is comparable to the best value reported for hBN single crystals obtained by NIMS lab (7.3 cm⁻¹) using the High Pressure High Temperature (HPHT) method^{36,48} and by Edgar's group (7.8 cm⁻¹) using nickel-chromium solvent.³⁸ The integrated intensity of the 52.6 cm⁻¹ signal is about a fortieth of the 1366.0 cm⁻¹ one (I_{low}/I_{high} \approx 1/43), which is consistent with published results.^{44,45} Both optical and Raman analyses fully attest the excellent crystallinity of the produced hBN.



Figure 2. Characterization of the bulk sample, a)- optical image; b)- optical microscopy image;

c)- XRD pattern; d, e)- respectively low and high frequency Raman spectra.

Obtaining hBN with such crystalline quality may be explained by using a large amount of Li₃N (35 wt.%) which plays a key role in the liquid-solid sintering mechanism. By comparing with previous studies in which only 5 wt.% of Li₃N was added,^{40,41} the growth mechanism is different. Although the Li based solvent seems to play an important role, the crystal growth process of hBN does not appear as a simple precipitation from a solution in molten lithium and the hBN crystals rather look like the product of a reaction in the ternary Li-B-N system. In that case, we can assume that the growth occurs in the liquid phase and the proposed crystallization mechanism is based on previous studies reported by Bezrukov⁴⁹ and other groups.^{50–52} At around 600–700 °C, Li₃BN₂ formed by reaction between Li₃N and preceramic BN, melts, and infiltrates amorphous BN to dissolve it, leading to highly crystallized hBN. Moreover, it can be noticed that our experiments have been performed in BN-crucibles, which may favor the nucleation of hBN.

hBN freestanding crystals and nanosheets. At the macroscopic scale, the raw material shows evidence for intertwining of large crystals. Freestanding, colorless and transparent hBN crystals of about 2 mm, can be easily extracted from this bulk sample, by simple sliding with tweezers (Figure 3a and 3b). To further reduce the crystals thickness in the c-axis direction, yet keeping them as large as possible along in-plane dimension, crystals have been exfoliated using a polydimethylsiloxane (PDMS) dry transfer (Figure 3c) and deposited onto an oxidized silicon substrate (285 nm thick SiO₂) (Figure 3d). Such isolated BNNSs present flat and smooth surfaces over distance varying from 100 μ m to more than 1 mm, that is larger than what is obtained with commercial samples which show a loss of their lateral size after exfoliation.^{33,34} Their

thicknesses were measured by Atomic Force Microscopy (AFM) (Figure 3e and 3f) and line profiles (Figure 3g) give typical step values of 4 - 6 nm, corresponding to approximately ten layers.



Figure 3. Microstructural characterization of hBN freestanding crystals and nanosheets, a, b)-optical images of freestanding crystals; c)- electron microscopy image of a BNNS transferred onto PDMS; d)- optical micrograph of a BNNS deposited onto Si/SiO₂ substrate; e)- AFM topography image of hBN nanosheets ; f)- corresponding 3D AFM image and g)- line profiles recorded along arrows 1 and 2 from image e indicating the nanosheets thickness.

After deposition, the crystalline signature of crystals was confirmed by XRD, and only hBN (002) and (004) peaks are observed (Figure 4a). This results from the perfect planar alignment of the (002) lattice planes onto the silicon supporting substrate. From the (002) line, we deduced an interplanar spacing of 3.328Å, consistent with the JCPDS data file (00-034-0421) for hBN. Further investigations of hBN thin crystals and nanosheets compared the Raman spectra (Figure 4b-d) for areas of different thicknesses, as identified by optical contrast (yellow spot on Figure 4e-g). Each region displays only the expected hBN E_{2g} vibration mode around 1365.5 cm⁻¹, with FWHM $\approx 8 \text{ cm}^{-1}$. When decreasing the hBN crystal thickness, the Raman peak intensity decreases, as already described in literature²⁹. At the same time, the FWHM increases from 8.1 cm⁻¹ to 8.7 cm⁻¹. Note that the FWHM of the E_{2g} peak is higher here than that observed previously on hBN bulk crystals (7.7 cm⁻¹). This feature has already been reported in the literature and can be attributed to a local strain occurring when nanosheets are transferred onto a substrate.²⁹



Figure 4. Structural characterizations of hBN freestanding crystals and BNNSs, a)- XRD pattern of an extracted crystal; b-d)- Raman spectra recorded on a BNNS for different thicknesses and e-

g)- optical images of the corresponding probed regions (yellow spot).



Figure 5. Chemical characterization of hBN single crystal surface, a)- XPS general survey before and after a 2 μ m surface etching ; b)- after etching B1s peak at 189 eV, bulk plasmon (BP) loss peak at ~214 eV and π plasmon (π P) loss peak at ~198 eV ; c)- after etching N1s peak at 397 eV, bulk plasmon loss peak (BP) at ~423 eV and π plasmon loss peak (π P) at ~406 eV and d,e)- after etching C1s and O1s binding energy ranges.

Chemical analyses by X-ray Photoemission Spectroscopy (XPS) were performed on a hBN single crystal before and after a 2 μ m Ar⁺ etching (Figure 5a). The diameter of the X-ray beam used in these XPS measurements is about 100 μ m, which is smaller than the crystal dimension (\approx 200x200 μ m²). The XPS-B1s (189 eV), N1s (397 eV), O1s (532 eV) and C1s (283 eV) peaks

are observed on the sample surface, corresponding to an elemental composition of 45.9, 46.2, 0.9 and 7.0 at.%, respectively, which gives a perfect stoichiometric B/N ratio of 0.99. The C1s and O1s peaks are no longer present in the spectrum after etching of the top crystal surface (Figure 5d and 5e, respectively), indicating that both are due to surface impurities and that the synthesized sample presents an excellent chemical purity. However, because of the preferential sputtering of nitrogen atoms during the Ar⁺ sputtering process, the B/N ratio cannot be used for quantitative composition analysis inside the crystal. Both the B1s and N1s core level spectra (Figure 5b and 5c, respectively) show binding energy loss features at ~9 and ~25 eV, respectively, higher than the core peak. These peaks are attributed to π plasmons (π P) and bulk plasmons (BP), respectively.⁵³ These XPS features are used in the literature as the fingerprints of hBN confirming the high quality and purity of hBN single crystals.^{53–55}

When deposited on the Transmission Electron Microscopy (TEM) grid, the nanosheet folds onto itself, due to its extremely low thickness (Figure 6a). On a folded well-oriented area, the observed aligned layers allow to determine the interplanar distance of 3.3 Å, as expected for hBN (Figure 6b). The Selected Area Electron Diffraction (SAED) pattern recorded on a flat part presents the expected set of six bright diffraction spots with hexagonal symmetry (Figure 6a inset). This demonstrates that the crystal has a single hexagonal structure orientation with a AA' atomic stacking along the c-axis.⁵⁶ This is also confirmed, at higher resolution, by the six hexagonally distributed dots observed on the Fast Fourier Transform (FFT) image obtained from the in-plane atomic arrangement of the nanosheets (Figure 6c, inset). A filtered image, reconstructed from this FFT (Figure 6c), confirms the well-crystallized structure. A 2.5 Å distance between two adjacent atomic columns is deduced (white dots, Figure 6d), which corresponds to the distance between the centers of two neighboring hexagonal rings and

therefore to the lattice spacing of hBN (Figure 6e). A B-N bond distance of 1.44 Å can then be calculated. This value is consistent with previous results, again attesting to the perfect structural quality of the synthesized hBN.



Figure 6. TEM-scale microstructural characterization of BNNSs, a)- BNNS deposited on a holey carbon film, inset : SAED pattern of the selected area ; b)- TEM image of a folded area showing the stacked planes with an interlayer distance of 3.3Å ; c)- HRTEM image of the BNNS, inset : corresponding FFT pattern ; d)- FFT reconstructed image of c, inset : grey value plot of the yellow line in the image d, allowing to determine distance between two hexagons and e)- hBN in-plane and inter-plane structures based on HRTEM image measurements.

CONCLUSION

In conclusion, a dual process involving a preceramic polymer combined with a sintering step has been used to produce millimeter-sized high purity hBN single crystals. Their perfect chemical and structural quality was shown from the nm to the mm scale in the as produced bulk, freestanding crystals and exfoliated nanometer thick sheets. It is worth mentioning that this process is conducted under softer conditions and/or much shorter time than the ones currently used to produce other free standing single crystals. This new synthesis method provides access to an ample supply of large hBN single crystals that can be easily exfoliated into BNNSs for integration in advanced 2D devices.

METHODS

hBN layers preparation and characterization. Pure borazine is obtained from a reaction between ammonium sulfate [(NH₄)₂SO₄, 99% purity, Aldrich] and sodium borohydride (NaBH₄, 98% purity, Aldrich) in tetraglyme heated to 120 °C according to a procedure described elsewhere⁵⁷ and purified twice by distillation. The liquid-state polymeric precursor is then obtained by polycondensation of borazine at 50 °C inside a pressure-sealed system under argon for 5 days, generating colorless polyborazylene (PBN) with a chemical formula (B_{3.0}N_{3.8}H_{4.0})_n as given by elemental analysis. A mixture of liquid PBN and 35wt% lithium nitride (Li₃N) is preceramized at 650°C during 1h under inert atmosphere of N₂. The preceramic powder is then introduced under nitrogen into a BN crucible and thereafter transferred into a pressure-controlled furnace. The chamber is purged with 3 cycles (N₂ filling followed by pumping) to remove oxygen and moisture. The temperature and the pressure are both increased in 30 minutes up to 1800°C and up to 180MPa with N₂. The dwelling time is 8 hours before cooling down to room temperature together with pressure release. The material is characterized by optical microscopy, X-ray diffraction (XRD) and Raman spectroscopy using a green laser ($\lambda = 532$ nm). The material can be quite easily separated from the bulk with tweezers, thereby yielding self-standing crystals. Finally, these crystals are exfoliated using the PDMS dry transfer method and deposited onto Si/SiO₂ (285 nm) substrates or holey carbon coated copper Transmission Electron Microscopy (TEM) grids. These freestanding thin crystals and nanosheets are characterized as being hBN by optical microscopy, Atomic Force Microscopy (AFM), Scanning Electron Microscopy (SEM), TEM, X-Ray Photoemission Spectroscopy (XPS), XRD and Raman spectroscopy

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